

Workshop - μ -contact-printing and nanoimprint lithography

Veranstaltung - Workshop - μ -contact-printing and nanoimprint lithography

Titel	Workshop - μ -contact-printing and nanoimprint lithography
Wann	Mo, 9. März 2015

Beschreibung

Workshop " μ -contact-printing and nanoimprint lithography"

March 9, 2015; Technische Universität Dresden

The μ -CP/NIL workshop aims to promote activities in development and applications of nanoimprint technologies and μ -contact-printing and to provide and intense exchange between academics and participants from industry.

An international community of experts will come together to discuss new research results, perspectives of future developments, and innovative applications with the topics including: Process Tools, Printing Processes, Stamp and Inking Materials, Applications in electronics, optoelectronics, solar cells, displays, LEDs.

Please find more information (program, registration) on the website:
http://www.chm.tu-dresden.de/ac1/nachwuchsforscher/nanoimprint_workshop2015.shtml

Lokalität - Dresden

Standort	Dresden
Ortsname	Dresden
Land	DE